## **ERRATUM**

Erratum: "Thermally stimulated exoelectron emission from hydrogenated amorphous carbon films" [J. Mater. Res. 7, 1805 (1992)]

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After this article was published in the July issue of *Journal of Materials Research*, the authors noticed a scratch on the right side of Fig. 4(b) in their copy of that issue. Although the scratch occurred during printing

and was not apparent on the figure in all copies of the July issue, the unmarred Fig. 4 is included here for clarification.

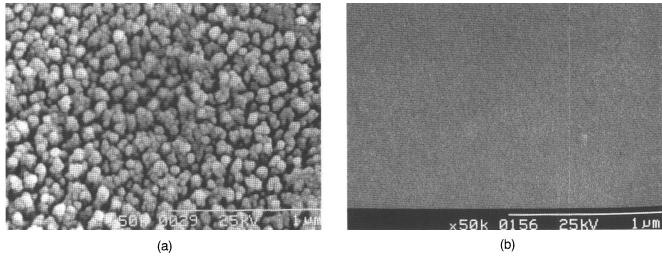


FIG. 4. SEM images of (a) the 80-nm a-C: H film and (b) the 280-nm a-C: H film.